

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

DATE MAILED: 04/04/2005

2370			
MINER			
LOUIE, WAI SING			
PAPER NUMBER			

Please find below and/or attached an Office communication concerning this application or proceeding.

		Appl	ication No.	/	Applicant(s)		
Office Action Summany				UK.			
			90,399		WILLIFORD, ETHAN		
	Office Action Summary		niner		Art Unit		
			Sing Louie	:41- 41	2814	l de a a a	
Period fo	The MAILING DATE of this commun or Reply	ncation appears o	n the cover sheet	with the c	orrespondence ad	iaress	
THE - Exte after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD F MAILING DATE OF THIS COMMUN nsions of time may be available under the provisions SIX (6) MONTHS from the mailing date of this com period for reply specified above is less than thirty (3) period for reply is specified above, the maximum s are to reply within the set or extended period for reply reply received by the Office later than three months ed patent term adjustment. See 37 CFR 1.704(b).	ICATION. s of 37 CFR 1.136(a). In munication. 30) days, a reply within ti atutory period will apply y will, by statute, cause t	no event, however, may ne statutory minimum of t and will expire SIX (6) Me ne application to become	a reply be tim hirty (30) days ONTHS from a ABANDONED	ely filed will be considered timel the mailing date of this co	ly. ommunication.	
Status							
1)🖾	Responsive to communication(s) file	ed on <u>10 March 2</u>	<u>2005</u> .				
2a)	This action is FINAL. 2b) This action is non-final.						
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposit	ion of Claims						
5)□ 6)⊠ 7)□	Claim(s) 1-29 is/are pending in the application. 4a) Of the above claim(s) 10-29 is/are withdrawn from consideration. Claim(s) is/are allowed. Claim(s) 1-9 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or election requirement.						
Applicat	ion Papers						
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority (under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
2) Notice 3) Information	nt(s) ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (mation Disclosure Statement(s) (PTO-1449 of the No(s)/Mail Date 10/20/03.		Paper N			O-152)	

DETAILED ACTION

Applicant's election without traverse of Group I, claims 1-9, in the reply filed on 3/10/2005 is acknowledge. It is suggested that non-elected claims 10-29 be canceled in the response to this Office Action.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-2, 5, and 7-9 are rejected under 35 U.S.C. 102(b) as being anticipated by Yilmaz et al. (US 5,136,349).

With regard to claims 1 and 5, Yilmaz et al. disclose a closed cell transistor with built-in voltage clamp (col. 4, line 34 to col. 10, line 45 and fig. 3), comprising:

- Spaced-apart source 48a and drain 48b regions formed in the substrate 60 (fig.
 3a);
- Channel region 64 defined between the source 48a and drain 48b regions (col. 5, line 51 and fig. 3a);

Application/Control Number: 10/690,399 Page 3

Art Unit: 2814

A layer of gate oxide 74 formed over at least a part of the channel region 64 (col.
5, lines 19-20 and fig. 3a);

• A gate 46 formed over the layer gate oxide 74, the gate 46 further having at least one implant aperture formed (fig. 3a), the channel region 64 of the substrate 60 further including a channel internal implanted (enhancement) region 40 between the source 48a and drain 48b regions (col. 5, lines 60-65 and fig. 3a).

With regard to claim 2, Yilmaz et al. disclose at least one lightly doped structure 68a located between at least one of the source 48a and drain 48b regions and the channel region 64 (fig. 3a).

With regard to claim 7, Yilmaz et al. disclose the LDD structure arranged between one of the source 48a and drain 48b regions and the channel region 64 (fig. 3a).

With regard to claims 8-9, Yilmaz et al. disclose a plurality of implant apertures arranged in a checkerboard configuration in a two dimensional array along the gate 46 (fig. 5).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Application/Control Number: 10/690,399

Art Unit: 2814

Claims 3 and 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yilmaz et al. (US 5,136,349).

With regard to claims 3 and 6, Yilmaz et al. disclose a channel internal implanted region 40 (fig. 3a), but do not disclose a lightly doped structure. However, Yilmaz et al. teach the region 40 becomes a diffusion source and, naturally, the substrate 60 is then subjected to a diffusing process (col. 8, lines 44-54). Thus, a lightly doped structure would be formed around the channel internal implanted region 40.

Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yilmaz et al. (US 5,136,349) in view of Lai et al. (US 6,649,461).

With regard to claim 4, Yilmaz et al. do not disclose the double-diffused structure 40 is implanted at a diagonal angle to the gate through the implant aperture. However, Lai et al. disclose an angle implant (Lai col. 8, lines 28-36 and fig. 4). Lai et al. teach the angle implant would reduce or eliminate the effects of narrow channel impurity diffusion to surrounding region of insulation (Lai col. 5, lines 48-51), which could cause the hot-carrier effect of the transistor (Lai col. 4, lines 20-35). Yilmaz et al. and Lai et al. have substantially the same environment of transistor having an oxide layer under the gate. Therefore, it would have been obvious for the one with ordinary skill in the art to modify Yilmaz's device with the teaching of Lai et al. to provide the angle implant through the gate implant aperture in order to avoid damaging the gate insulation.

Art Unit: 2814

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Wai-Sing Louie whose telephone number is (571) 272-1709. The examiner can normally be reached on 7:30 AM to 4:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

March 30, 2005.